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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/046,233	01/16/2002	Hidefumi Sakata	111245	3434
25944	7590 08/18/2004		EXAMINER	
OLIFF & BI	ERRIDGE, PLC		LEFLORE,	LAUREL E
P.O. BOX 199	928			
ALEXANDRIA, VA 22320			ART UNIT	PAPER NUMBER
			2673	

DATE MAILED: 08/18/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

1 (S	\Im					
3	¥	Application No.	Applicant(s)			
		10/046,233	SAKATA ET AL.			
Office Action Summary		Examiner	Art Unit			
		Laurel E LeFlore	2673			
 Period for	The MAILING DATE of this communication app Reply	ears on the cover sheet with the d	correspondence address			
THE M - Extens after S - If the p - If NO p - Failure Any re	PRTENED STATUTORY PERIOD FOR REPLY IAILING DATE OF THIS COMMUNICATION. Is considered the provisions of 37 CFR 1.1. IX (6) MONTHS from the mailing date of this communication. It is communication that is communication that is communication to reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period to reply within the set or extended period for reply will, by statute ply received by the Office later than three months after the mailing a patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	mely filed /s will be considered timely. If the mailing date of this communication. D (35 U.S.C. § 133).			
Status						
1)⊠ F	Responsive to communication(s) filed on <u>18 Ju</u>	<u>ıne 2004</u> .				
2a)	This action is FINAL . 2b)⊠ This	action is non-final.				
	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
(closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 4	53 O.G. 213.			
Dispositio	on of Claims					
5)□ (6)⊠ (7)□ (Claim(s) <u>1-18</u> is/are pending in the application. a) Of the above claim(s) is/are withdray Claim(s) is/are allowed. Claim(s) <u>1-18</u> is/are rejected. Claim(s) is/are objected to.	vn from consideration.				
8) [(Claim(s) are subject to restriction and/o	r election requirement.				
Applicatio	on Papers					
10)⊠ T , , ,	The specification is objected to by the Examine The drawing(s) filed on 16 January 2002 is/are: Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Ex	a) \boxtimes accepted or b) \square objected drawing(s) be held in abeyance. Se ion is required if the drawing(s) is ob	e 37 CFR 1.85(a). ejected to. See 37 CFR 1.121(d).			
·	,					
	nder 35 U.S.C. § 119					
a)⊠ 2	acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority document: 2. Certified copies of the priority document: 3. Copies of the certified copies of the priority document: application from the International Bureaute the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	ion No ed in this National Stage			
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Attachment(s) of References Cited (PTO-892)	4) Interview Summary	(PTO-413)			
2) Notice 3) Inform	of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) No(s)/Mail Date 3/24/04, 6/18/04.	Paper No(s)/Mail D				

DETAILED ACTION

Claim Rejections - 35 USC § 112

- 1. The following is a quotation of the first paragraph of 35 U.S.C. 112:
 - The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.
- 2. Claims 1-16 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. Independent claims 1 and 16 recite "a plurality of projections formed from the at least one of the pair of transparent electrodes" and "a plurality of projections formed from at least one of the lower transparent electrode and the input transparent electrode". However, the specification, as originally filed recites that the plurality of projections are formed ON the transparent electrodes or on the flat substrate under the transparent electrodes. See, for instance, paragraphs [0019], [0020], and [0023] of the original specification. Also note in the figures (see, for instance, figure 4) that projections 21 and 22 are formed on the flat substrates 11 and 12 with the transparent electrodes 15 and 16 formed on the projections. Thus, the claimed recitation of projections "formed from the...transparent electrodes" is not disclosed in the specification as originally filed.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1-18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Inou 6,078,274 in view of Raj et al. 6,326,723 B1.

In regard to claims 1, 8, 13 and 16, Inou discloses a touch panel that comprises a pair of substrates (one of which is flexible) opposing each other and having a predetermined spacing therebetween (See figure 1, elements 1 and 3. See column 4, lines 33-37, disclosing "the insulating substrate 1 and the flexible insulating substrate 3 are held 10μm apart".), and a pair of transparent electrodes having a respectively predetermined pattern, each of the transparent electrodes being formed on an inner surface of each of the pair of substrates. See figure 1, elements 2a and 2b and column 4, lines 20-32, disclosing "an insulating substrate 1...on which is provided a transparent conductive film 2a...and a flexible insulating substrate 3...on which is provided a transparent conductive film 2b." It is understood that the two transparent conductive films are a pair of transparent electrodes, as they are both conductive layers that are formed of the same material (indium tin oxide) and are formed "substantially on the entire inner surfaces of the" substrates. (See paragraph [0005] of the specification of the claimed invention.) Inou further discloses a plurality of projections formed from the surface of at least one of the pair of transparent electrodes, the projections

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being formed to have a substantially periodical pitch. See figures 1 and 2, element 8, figure 3, and column 4, lines 42-46, discloses that, "On the transparent insulating films 2a and 2b, antireflective films 8 are provided by. For example, offset printing, in the form, shown in FIG. 3, of square islets 100 nm thick, each with a pitch Pd of $100\mu m$ ". Thus, and in regard to claim 13, these projections of the transparent electrode are formed on a flat substrate (see figure 1).

Inou differs from the claimed invention in that the projections in Inou's invention have a pitch of 50μm at the smallest (see figure 8) and thus do not have a pitch "that is shorter than any wavelength of visible light." Raj et al. discloses a plurality of projections (see figure 6, element 16) stating, in column 3, lines 21-22, "The elements 16 may be fabricated on planarized surfaces using a technique called holographic lithography which allows patterning by the interference. Feature sizes as small as 90 nanometers may be formed over large areas. Using this technique, moth-eye like surface relief array structures may be formed of an array of microscopic protrusions." In column 4, lines 28-32, Raj et al. further discloses that "the moth-eye like elements 16 may have relatively small feature sizes. For example in one embodiment of the invention, those feature sizes can be on the order of 100 nanometers. This means that there will be numerous scattering centers of a small region." It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the invention of Itou by making the projections have a pitch shorter than any wavelength of visible light, such as 100 nanometers, as disclosed by Raj et

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al. One would have been motivated to make such a change based on the teaching in column 3, lines 3-5, of Raj et al. to include a plurality elements for absorbing light on the substrate, as (see column 3, lines 13-14) such "light trapping reduces back reflections or glare".

- 5. In regard to claim 2, Inou discloses an air space bing formed between the pair of transparent electrodes. See figure 1, element 6 and column 4, lines 33-37. Also see rejection of claim 1.
- 6. In regard to claim 3, 4 and 6 Inou in view of Raj et al. discloses an invention that is similar to the claimed invention. See the rejection of claim 1 for similarities. Inou does not disclose that the projections become continuously smaller from a bottom to a top thereof, as a cone. Raj et al. discloses, "A variety of shapes and sizes of the moth-eye elements 16 may be formed, including...the conical elements 16 shown in FIG. 5. These structures have low reflectance over large wavelength bands and angular acceptance ranges." It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the invention of Inou in view of Raj et al. having the projections becoming continuously smaller from the bottom to the top, as a cone. One would have been motivated to make such a change based on the teaching of Raj et al. that such a shape would have low reflectance and angular acceptance ranges, thus further increasing light transmittance.
- 7. In regard to claim 5, Inou in view of Raj et al. discloses an invention that is similar to the claimed invention. See the rejections of claims 1, 3, 4 and 6 for similarities. Inou does not disclose that the projections become smaller in a

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stepwise manner from the bottom to the top thereof. However, if the projections became smaller in a stepwise manner, and the steps were very small, then the projections would be becoming smaller in a continuous manner. Thus, the projections becoming smaller in a stepwise manner or continuous manner would be equivalents if the steps were small enough. Further, there is no disclosed criticality of the steps becoming smaller in a stepwise or continuous manner. Thus, change in form/shape is a design choice of no disclosed criticality. (Refer to in re Dailey, 149 USPQ 47 (CCPA 1976).)

- 8. In regard to claim 7, Inou further discloses that the plurality of projections is arranged with a substantially periodical pitch in at least two directions. Refer to figures 3-11, depicting various embodiments with intervals and pitches that are periodic.
- 9. In regard to claims 9 and 10, Inou discloses the plurality of projections is formed with the same pattern on both of the pair of transparent electrodes. See rejection of claim 1 and column 10, lines 26-30, which discloses that the foregoing embodiments may include such projections (which each have specific patterns of projections) on one or both of the conductive films. See figures 3-11, showing the patterns for the foregoing embodiments.
- 10. In regard to claim 11, Inou discloses that the plurality of projections formed on the surface of one of the pair of transparent electrodes has a pattern different from that of the other transparent electrode. See column 10, lines 26-30, which disclose that the projections may be formed on only one of the transparent films.

Thus, the pattern on this one film would be different than the pattern on the film without projections.

- 11. In regard to claim 14, Inou discloses a plurality of spacers positioned between the pair of transparent electrodes that maintain the spacing between the pair of transparent electrodes. See figures 2-3, element 4 and column 4, lines 28-37 disclosing spacers.
- 12. In regard to claim 15, Itou discloses that the touch panel is at least one of an analog resistive contact type, a digital resistive contact type, and an electrostatic capacitive coupling type. See column 1,lines 10-21, disclosing various types of touch panels to which the invention relates, including analog and digital resistive and capacitance-detecting.
- 13. In regard to claim 17, see rejection of claims 1, 16 and 14.
- 14. In regard to claim 18, see rejection of claims 1, 16 and 14.

Response to Arguments

- 15. Applicant's arguments filed 18 June 2004 have been fully considered but they are not persuasive.
- 16. In regard to applicants arguments that Inou does not disclose "that the plurality of projections are formed from the at least one of the pair of transparent electrodes", see rejection of claim 1. Note that the projections are printed on the pair of transparent electrodes and protrude from them. Thus, the projections are formed from the transparent electrodes. Further note the 112, first paragraph rejection of claims 1-16 regarding this recitation in the claims.

Conclusion

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17. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Saif et al. 6,583,935 B1 discloses a conductive layer with a thickness that is less than the wavelength of visible light for reduced reflection and increased light transmission.

Noda et al. JP11-250764 A discloses a touch panel with transparent electrode layers that have a rough surface.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Laurel E LeFlore whose telephone number is (703) 305-8627. The examiner can normally be reached on Monday-Friday 8-4:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bipin Shalwala can be reached on (703) 305-4938. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

LEL 12 August 2004

BIPIN SHALWALA

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2600